

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re Application of:)	
)	
Kloster, et al.)	
)	
U.S. Serial No: 09/820,079)	Examiner: Loke, Steven Ho Yin
)	
Filed: March 28, 2001)	Art Unit: 2811
)	
For: STRUCTURE IN A)	
MICROELECTRONIC DEVICE)	
INCLUDING A BI-LAYER FOR)	
A DIFFUSION BARRIER AND)	
AN ETCH STOP LAYER)	
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Commissioner for Patents		
P.O. Box 1450		
Alexandria, VA 22313-1450		

AMENDMENT AND RESPONSE

Dear Sir:

This is in response to the Office Action mailed May 26, 2006. Applicant respectfully requests the Examiner to enter the following amendments and consider the following remarks.

Amendments to the Claims are reflected in the listing of claims that begins on page 2 of this paper. **Remarks/Arguments** begin on page 7 of this paper.